

Title (en)

METHOD FOR FORMING A PRIMING LAYER FOR DEPOSITING A METAL ON A SUBSTRATE

Title (de)

VERFAHREN ZUM BILDEN EINER VORBEREITUNGSSCHICHT ZUM ABSCHIEDEN EINES METALLS AUF EINEM SUBSTRAT

Title (fr)

PROCEDE DE FORMATION D'UNE COUCHE D'AMORCAGE DE DEPOT D'UN METAL SUR UN SUBSTRAT

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Application

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Abstract (en)

[origin: WO2009125143A2] The invention relates to a method for forming, on a substrate (5), a priming layer enabling a subsequent deposit of a layer of a metal, which comprises immersing the substrate in a bath (7) including a material in the ethoxysilanes or siloxanes families and a copper or nickel amidinate.

IPC 8 full level

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Citation (search report)

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